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10/26/01

PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10001333	FILING DATE 10/26/2001	CLASS 250	SUBCLASS 595	GAU 2881	EXAMINER Meeke
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\*\*APPLICANTS: Kaito Takashi;

\*\*CONTINUING DATA VERIFIED:  
*After Name*

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\*\* FOREIGN APPLICATIONS VERIFIED:  
JAPAN 2000-333368 10/31/2000  
*Tak*

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed 35 USC 119 conditions met	<input type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> yes <input type="checkbox"/> no	ATTORNEY DOCKET NO S004-4433
TITLE : Beam shaped film pattern formation method		
U.S.DEP.T. OF COMM./PAT. & TM-PTO-436L(Rev. 12-94)		

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
			Total Claims	Print Claim for O.G
ISSUE FEE		Primary Examiner	DRAWING	
Amount Due	Date Paid		Sheets Drwg.	Figs.Drwg.
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE		Application Examiner
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